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(12) **United States Design Patent**  
**Kamimura et al.**

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(54) **PRESSING MEMBER FOR SUBSTRATE  
POLISHING APPARATUS**

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(51) **LOC (11) Cl.** ..... **15-09**

(52) **U.S. Cl.**  
USPC ..... **D15/126**

(58) **Field of Classification Search**  
USPC ..... D8/70, 71; D15/126, 138  
CPC ..... B24B 9/065; B24B 21/004; B24B 37/27  
See application file for complete search history.

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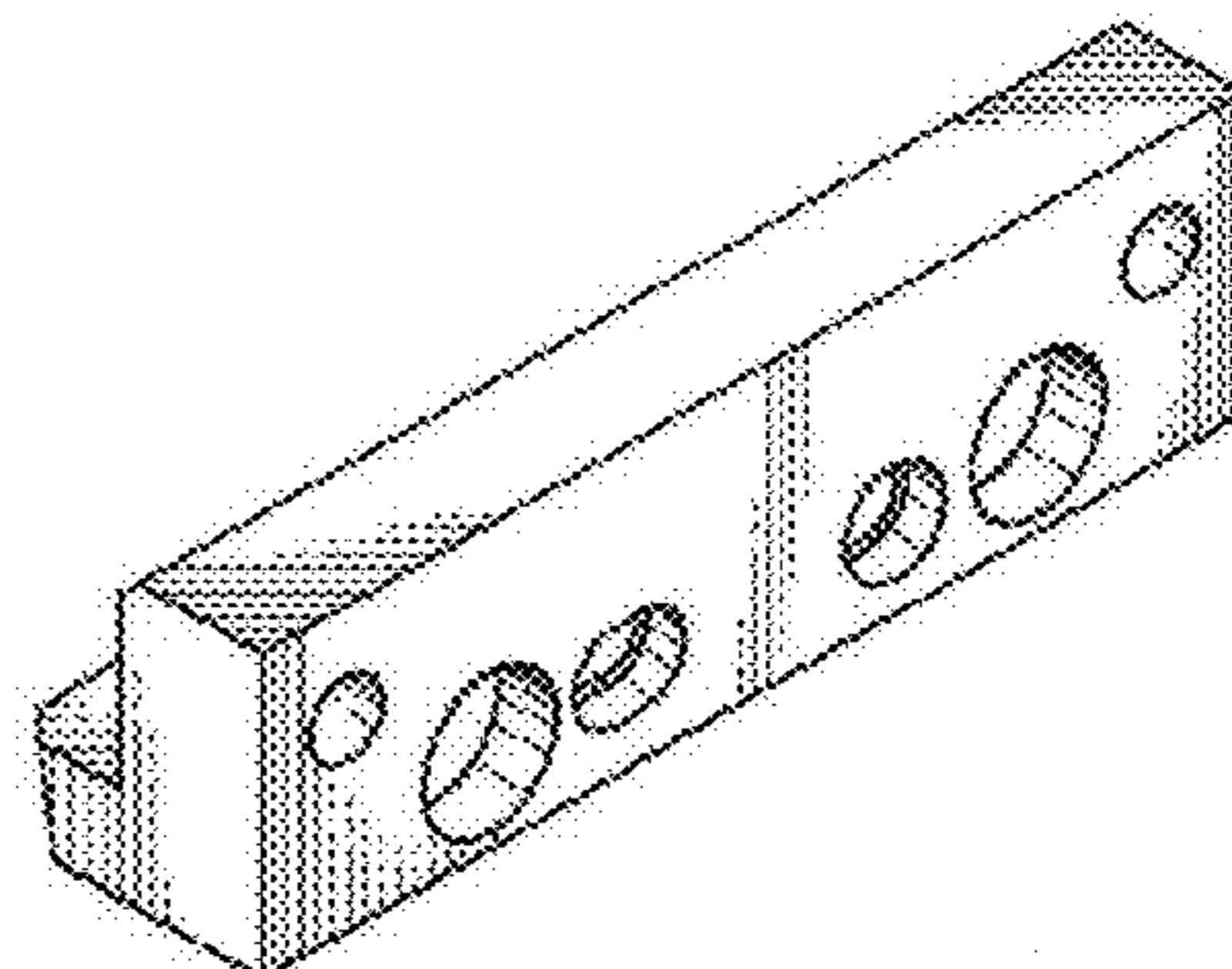
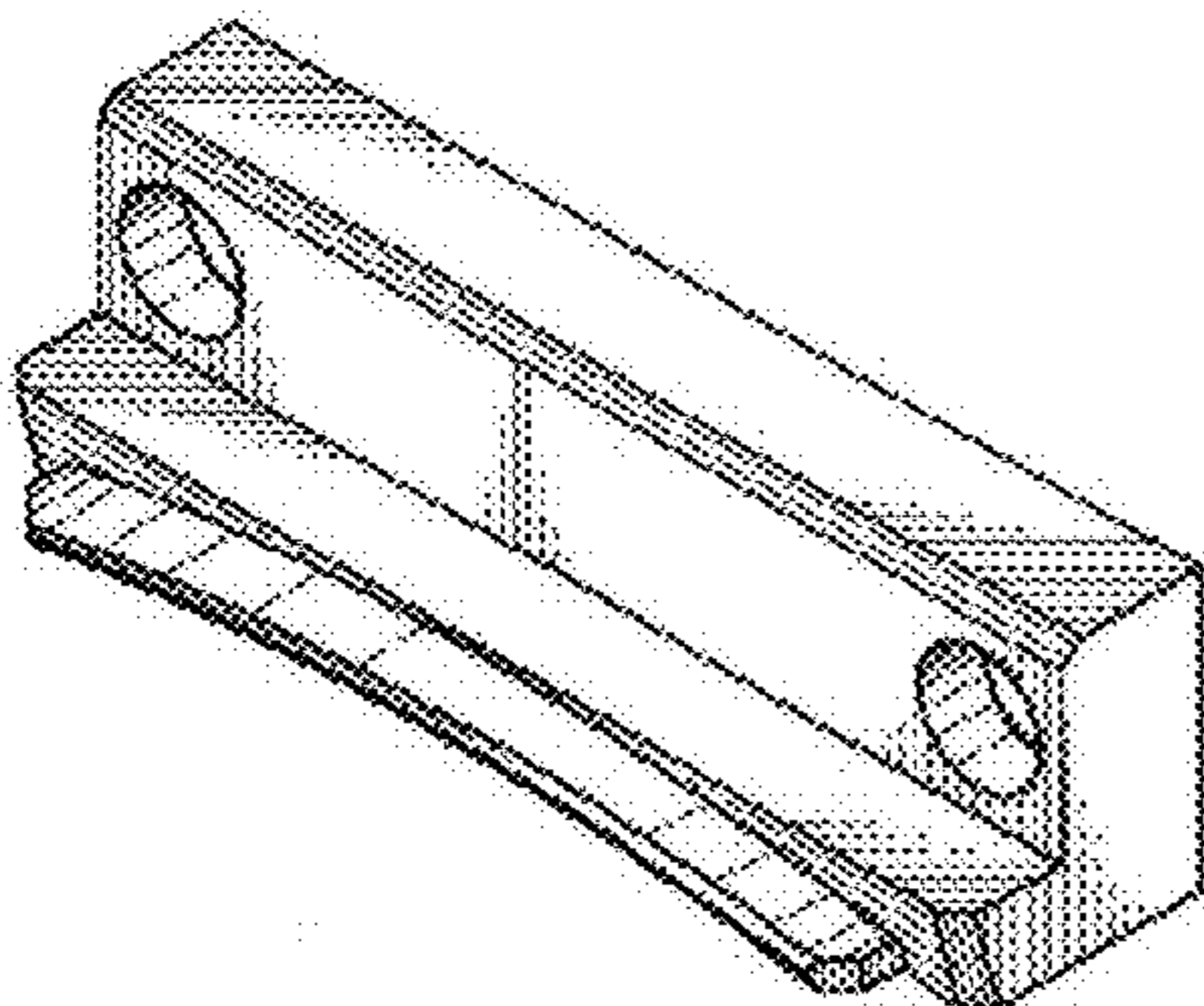
(57) **CLAIM**

The ornamental design for a pressing member for a substrate polishing apparatus, as shown and described.

**DESCRIPTION**

FIG. 1 is a first perspective view, observed from a front of a pressing member for a substrate polishing apparatus showing our new design;  
FIG. 2 is a second perspective view, observed from a rear thereof;  
FIG. 3 is a front view thereof;  
FIG. 4 is a rear view thereof;  
FIG. 5 is a top view thereof;  
FIG. 6 is a bottom view thereof; and,  
FIG. 7 is a right-side view thereof, a left-side view being a mirror image thereof.

**1 Claim, 2 Drawing Sheets**



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FIG.1

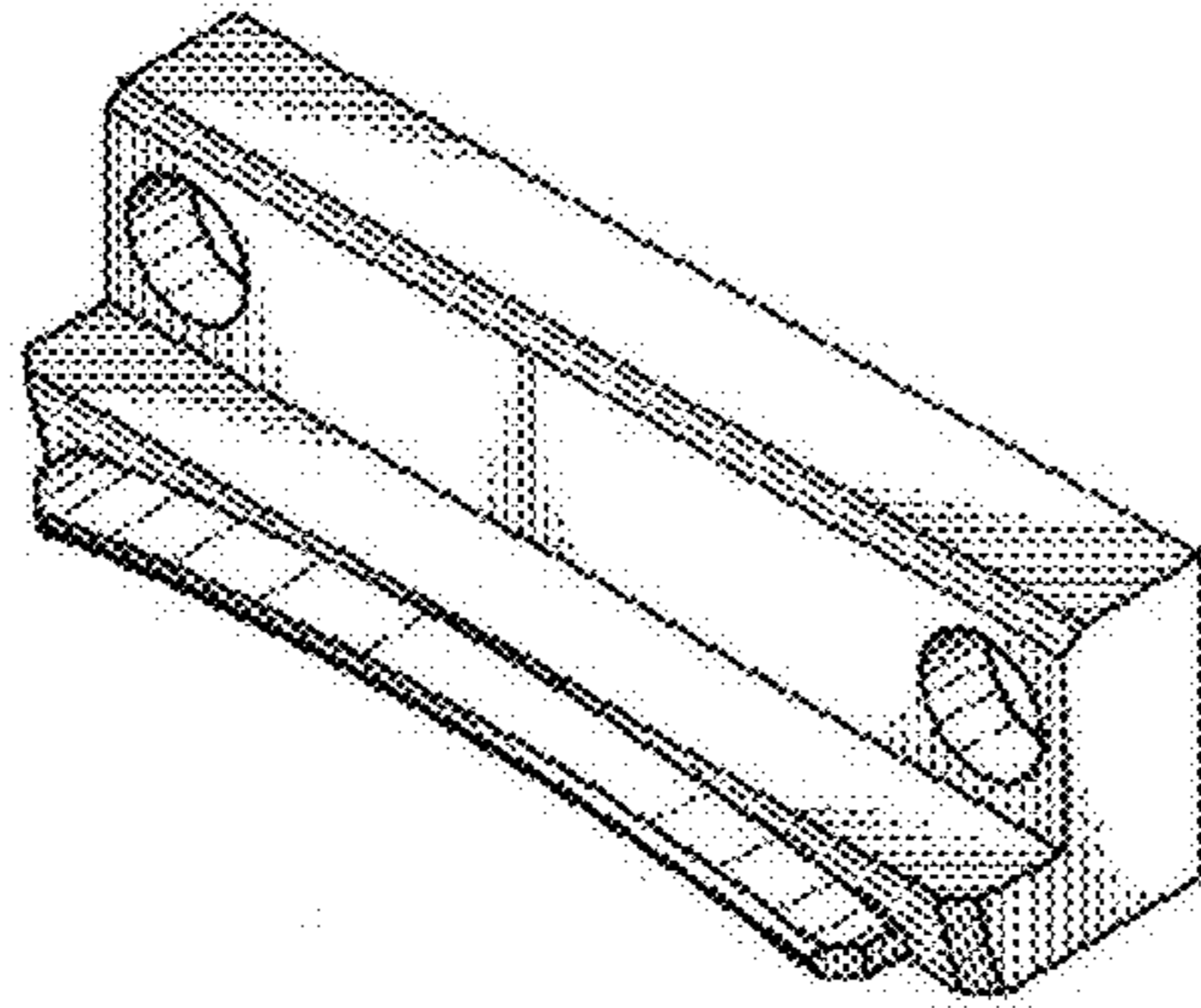


FIG.2

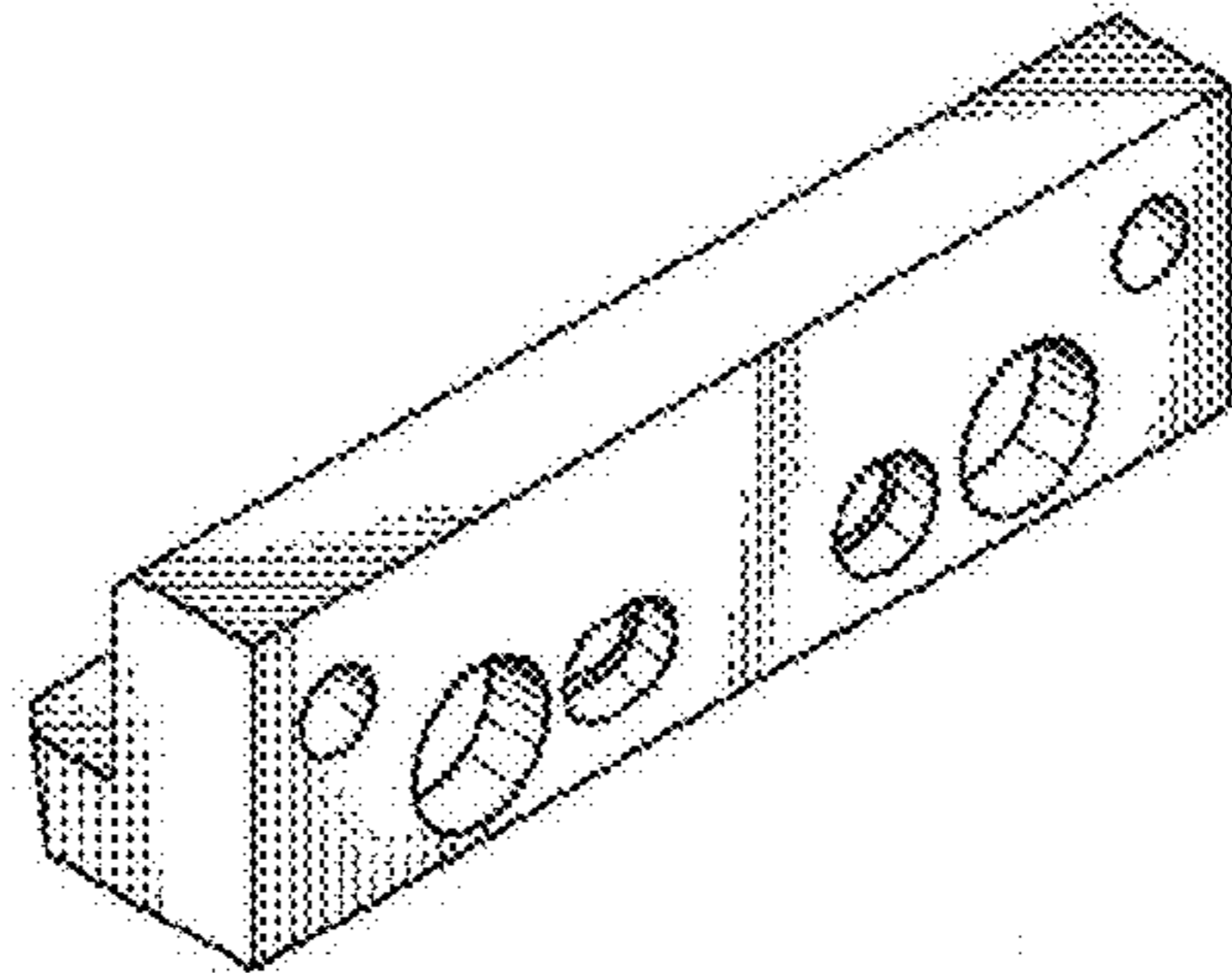


FIG.3



FIG.7

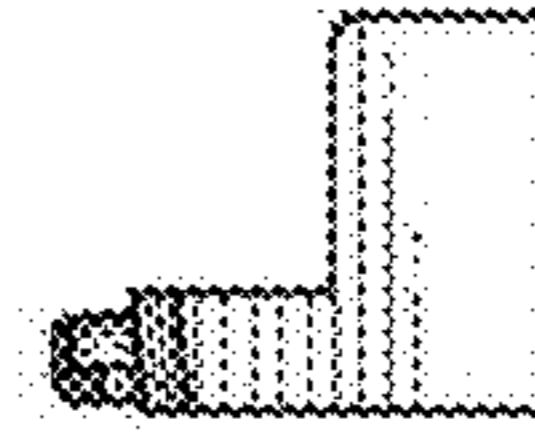


FIG.4

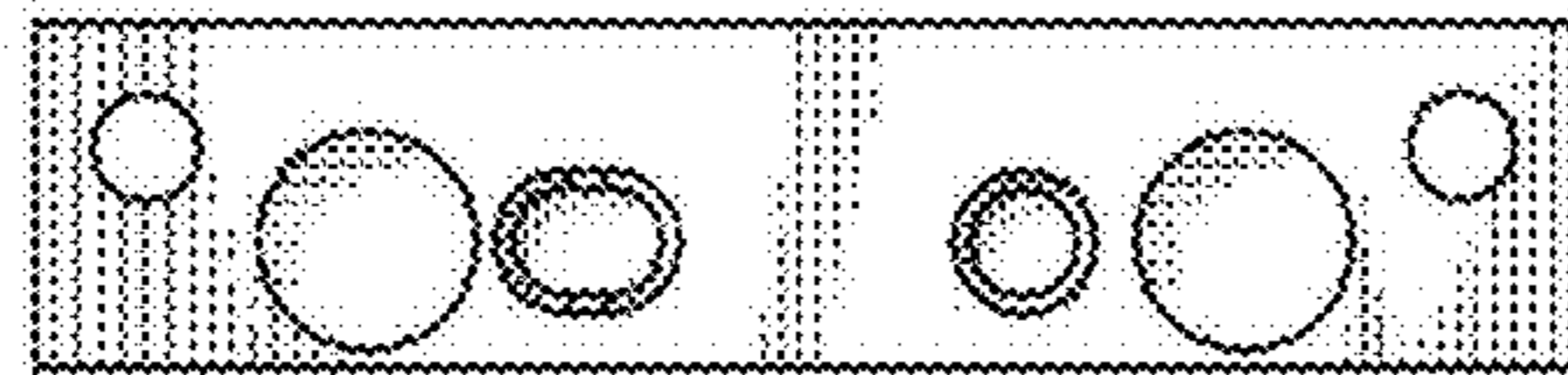


FIG.5

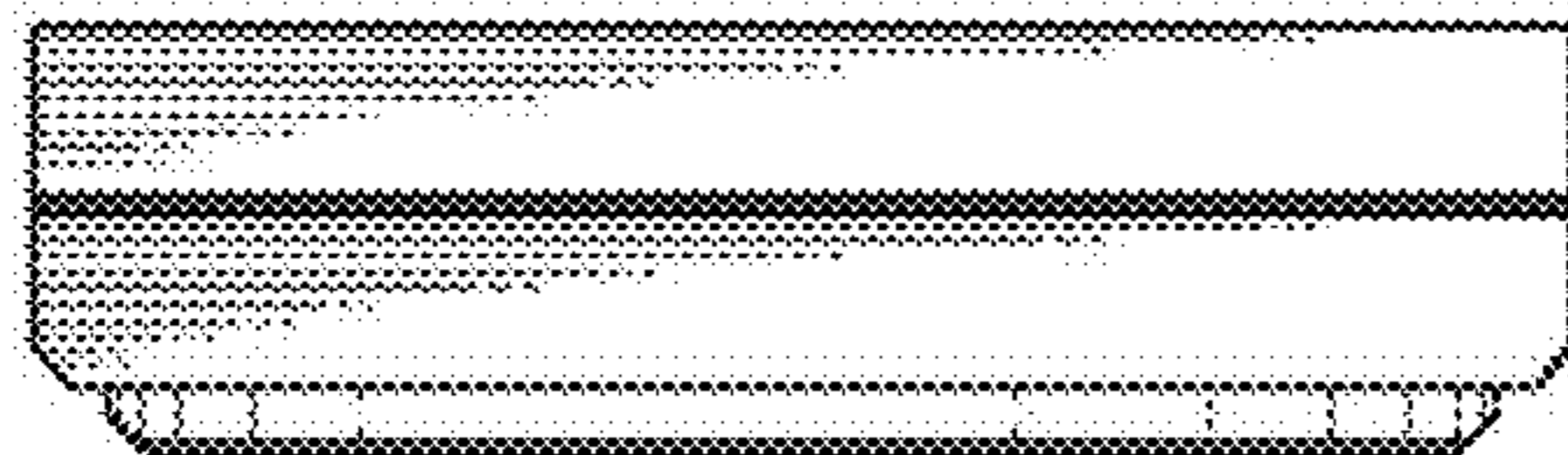


FIG.6

